Docket No.

219587US90

N THE WINITED TATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF:

Masato HAMATANI, et al.

SERIAL NO:

10/072,866

GAU:

2851

FILED:

February 12, 2002

EXAMINER: FULLER, R.

FOR:

SPECIFICATION DETERMINING METHOD, PROJECTION OPTICAL SYSTEM MAKING METHOD AND ADJUSTING METHOD, EXPOSURE APPARATUS AND MAKING METHOD THEREOF, AND COMPUTER

SYSTEM

INFORMATION DISCLOSURE STATEMENT UNDER 37 CFR 1.97

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

SIR

Applicant(s) wish to disclose the following information.

REFERENCES

- The applicant(s) wish to make of record the references, some of which are cited in the U.S. Office Action for the co-pending application No. 10/608,032, the attached International Search Report for the co-pending application No. 10/608,032, the attached European Search Report, the attached Australian Search Report or the attached Australian Written Opinion, listed on the attached form PTO-1449. Copies of the listed references are attached, where required, as are either statements of relevancy or any readily available English translations of pertinent portions of any non-English language references.
- A check or credit card payment form is attached in the amount required under 37 CFR §1.17(p).

RELATED CASES

- Attached is a list of applicant's pending application(s) or issued patent(s) which may be related to the present application. A copy of the patent(s), together with a copy of the claims and drawings of the pending application(s) is attached along with PTO 1449.
- A check or credit card payment form is attached in the amount required under 37 CFR §1.17(p).

CERTIFICATION

- ☐ Each item of information contained in this information disclosure statement was first cited in any communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of this statement.
- □ No item of information contained in this information disclosure statement was cited in a communication from a foreign patent office in a counterpart foreign application or, to the knowledge of the undersigned, having made reasonable inquiry, was known to any individual designated in 37 CFR §1.56(c) more than three months prior to the filing of this statement.

DEPOSIT ACCOUNT

Please charge any additional fees for the papers being filed herewith and for which no check or credit card payment is enclosed herewith, or credit any overpayment to deposit account number 15-0030. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

08/04/2004 WABDELR1 00000130 10072866

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OF 2 SHEET U.S. DEPARTMENT OF COMMERCE PATENT AND TANDEMARK OFFICE TRADE SERIAL NO. ATTY DOCKET NO. Form PTO 1449 (Modified) 10/072,866 219587US90 APPLICANT LIST OF REFERENCES CITED BY APPLICANT Masato HAMATANI, et al. FILING DATE **GROUP** 2851 February 12, 2002 U.S. PATENT DOCUMENTS FILING DATE **EXAMINER** DOCUMENT SUB DATE NAME **CLASS** IF APPROPRIATE INITIAL NUMBER **CLASS** AA 6,248,486 06/19/2001 DIRKSEN, et al. 2002/0008869 A1 01/24/2002 VAN DER LAAN, et al. AB AC 2002/0036758 A1 03/28/2002 DE MOL, et al. 2002/0191165 A1 BASELMANS, et al. AD 12/19/2002 5,978,085 AE 11/02/1999 SMITH, et al. OOTAKI, et al. AF 6,078,554 06/20/2000 AG 6,118,535 09/12/2000 GOLDBERG, et al. AΗ 6,100,978 08/08/2000 NAULLEAU, et al. ΑI 2002/0001071 A1 01/03/2000 NOMURA, et al. 05/19/1998 AJ 5,754,299 SUGAYA, et al. AK 6,329,112 12/11/2001 FUKUDA, et al. **FOREIGN PATENT DOCUMENTS TRANSLATION** DOCUMENT DATE COUNTRY **NUMBER** NO **EUROPE** ΑK 1 160 626 12/05/2001 WO 00/31592 06/02/2000 **WIPO** AL 1 128 217 08/29/2001 **EUROPE** AM AN 10-154657 06/09/1998 Japan (w/ English abstract) х AO 2000-121491 04/28/2000 Japan (w/ English abstract) x ΑP WIPO (w/ English bbstract) WO 99/60361 11/25/1999 AQ 1 079 223 02/28/2001 **EUROPE** 11-118613 AR 04/30/1999 Japan (w/ English abstract) х 6-235619 08/23/1994 AS Japan (w/ English abstract) x AT 5-296879 11/12/1993 Japan (w/ English abstract) x ΑU 2000-47103 02/18/2000 Japan (w/ English abstract) x ΑV 2000-331923 11/30/2000 Japan (w/ English abstract) х AW 08/27/1999 11-233424 Japan (w/ English abstract) х AX 198 20 785 A1 10/21/1999 Germany x AY 2000-121491 04/28/2000 Japan (w/ English abstract and translation) х ΑZ 2000-146757 05/26/2000 Japan (w/ English abstract and machine translation) x BA 09/29/2000 2000-266640 Japan (w/ English abstract and machine translation) x BB WO 00/55890 a 09/21/2000 WIPO (w/ English abstract) X BC 2001-230193 08/24/2001 Japan (w/ English abstract and machine translation) х BD 1 160 626 A1 12/05/2001 Europe BF 1 355 140 A1 10/22/2003 Europe (corresponding to U.S. Application 10/608,032) BG 1 359 608 A1 11/05/2003 Europe WO 02/50506 A1 06/27/2002 BH WIPO (w/ English abstract) Additional References sheet(s) attached

*Examiner: Initial if reference is considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Date Considered

Examiner

SHEET 2 OF 2

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Form PTO 1449	U.S. DEPARTMENT OF COMMERCE	ATTY DOCKET NO.	SERIAL NO.
(Modified)	PATENT AND TRADEMARK OFFICE	219587US90	10/072,866
	APPLICANT		
LIST OF REFERENCES CITED BY APPLICANT		Masato HAMATANI, et al.	
		FILING DATE	GROUP
		February 12, 2002	2851
OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, etc.)			
AA	Title: "The influence of lens aberrations in lithography"		
AA	Journal of Vacuum Science & Technology B: Microelectronics Processing and Phenomena, American Vacuum Society, New York, NY, US, vol. 16, no. 6, November 1998 (1998-11) pages 3435-3439 Authors: K. Goldberg, et al. Title: "High-accuracy interferometry of extreme ultraviolet lithographic optical system"		
AA	SPIE Microlithography Seminar, pages 1-14 Authors: Donis G. Flaggelo, et al. Title: "TOWARDS A COMPREHENSIVE CONTROL OF FULL-FIELD IMAGE QUALITY IN OPTICAL PHOTOLITHOGRAPHY"		
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